

Notice of References Cited		Application/Control No. 10/551,843	Applicant(s)/Patent Under Reexamination OHMI ET AL.	
		Examiner GRANT S. WITHERS	Art Unit 2812	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
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FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)		
	U	Hamelmann, F. "W/Si multilayers deposited by hot-filament MOCVD" Thin Solid Films 338 (1999) pp 70-74		
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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